

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	167	438/671.ccls.	USPAT	OR	OFF	2005/03/08 11:44
L2	161	438/736.ccls.	USPAT	OR	OFF	2005/03/08 11:44
L3	510	438/243.ccls.	USPAT	OR	OFF	2005/03/08 11:44
L4	876	430/312.ccls.	USPAT	OR	OFF	2005/03/08 11:45
L5	1583	430/313.ccls.	USPAT	OR	OFF	2005/03/08 11:47
L6	247	438/717.ccls.	USPAT	OR	OFF	2005/03/08 11:47
L7	661	438/725.ccls.	USPAT	OR	OFF	2005/03/08 11:48
L8	129	438/950.ccls.	USPAT	OR	OFF	2005/03/08 11:48
L9	144	438/952.ccls.	USPAT	OR	OFF	2005/03/08 11:49
L10	151	438/948.ccls.	USPAT	OR	OFF	2005/03/08 11:52
L11	6	chen-xiaochun\$.in. cheng-kangguo\$.in. randall-mai\$. in.	USPAT	OR	OFF	2005/03/08 11:51
L12	9	chen-xiaochun\$.in. cheng-kangguo\$.in. randall-mai\$. in.	US-PGPUB	OR	OFF	2005/03/08 11:51
L13	1	chen-xiaochun\$.in. cheng-kangguo\$.in. randall-mai\$. in.	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/08 11:51
L14	83293	(substrate wafer) and (resist photoresist) and pattern\$6	USPAT	OR	ON	2005/03/08 11:56
L15	61617	14 and ((resist photoresist) same pattern\$6)	USPAT	OR	ON	2005/03/08 11:53
L16	8998	15 and ring	USPAT	OR	ON	2005/03/08 11:55
L17	7534	16 and (hard mask\$6)	USPAT	OR	ON	2005/03/08 11:55
L18	1740	17 and (ring same (resist photoresist))	USPAT	OR	ON	2005/03/08 11:56
L19	7478	(substrate wafer) and (resist photoresist) and pattern\$6 and ring	US-PGPUB	OR	ON	2005/03/08 11:56
L20	1238	19 and (ring same (resist photoresist))	US-PGPUB	OR	ON	2005/03/08 11:56
L21	909	(substrate wafer) and (resist photoresist) and pattern\$6 and ring	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 11:56
L22	416	21 and (ring same (resist photoresist))	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 11:56